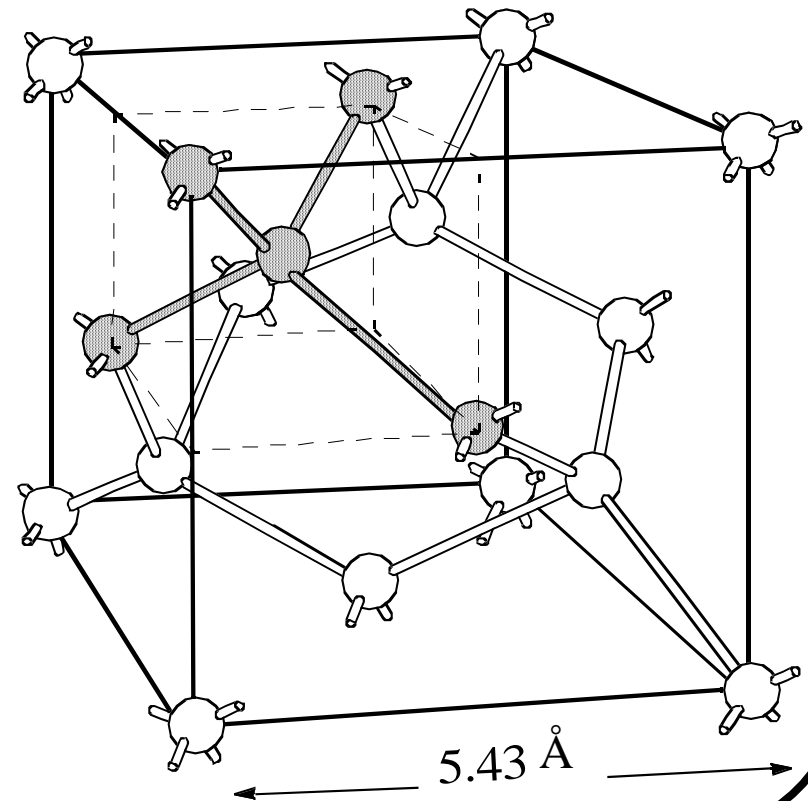


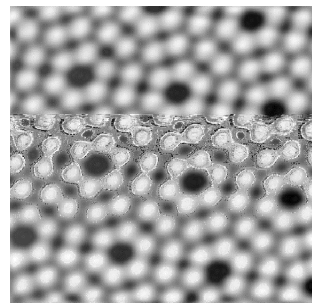
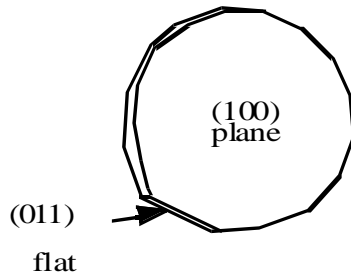
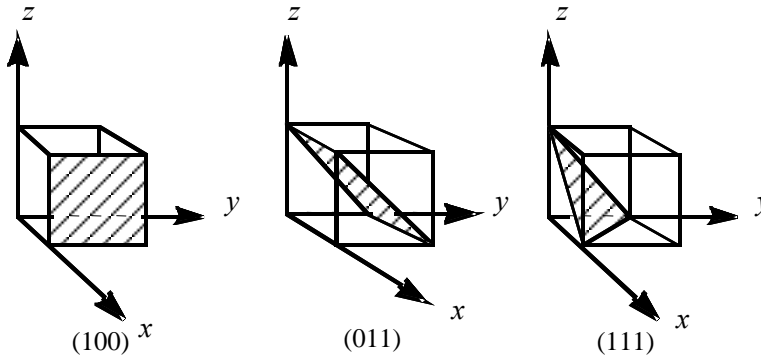
# *Chapter 1 Electrons and Holes in Semiconductors*

## *1.1 Silicon Crystal Structure*

- *Unit cell* of silicon crystal is cubic.
- *Each Si atom has 4 nearest neighbors.*



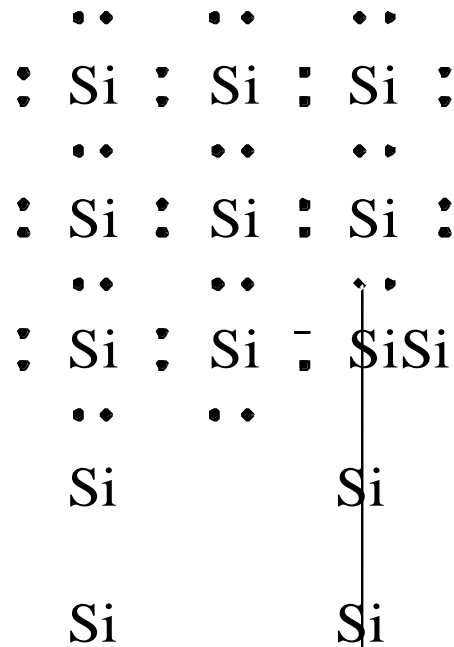
# *Silicon Wafers and Crystal Planes*



Si (111) plane

- The standard notation for crystal planes is based on the cubic unit cell.
- Silicon wafers are usually cut along the (100) plane with a flat or notch to help orient the wafer during IC fabrication.

## 1.2 *Bond Model of Electrons and Holes*



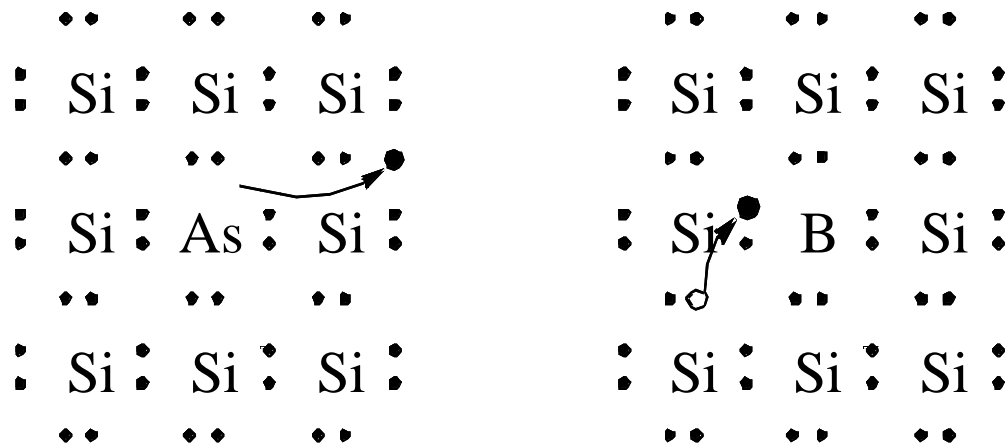
- Silicon crystal in a two-dimensional representation.

Si Si

Si

Si

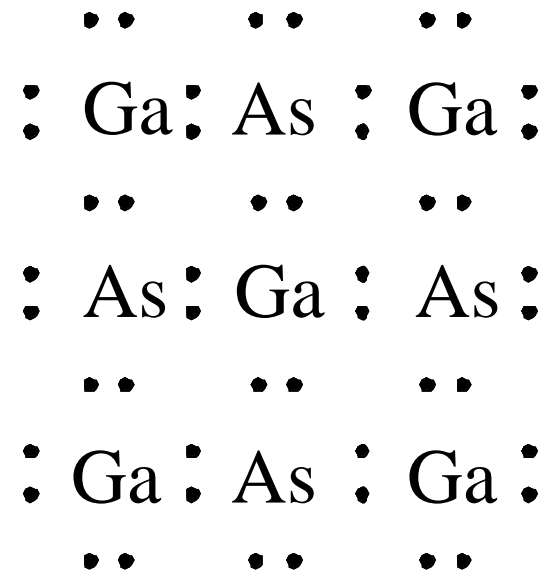
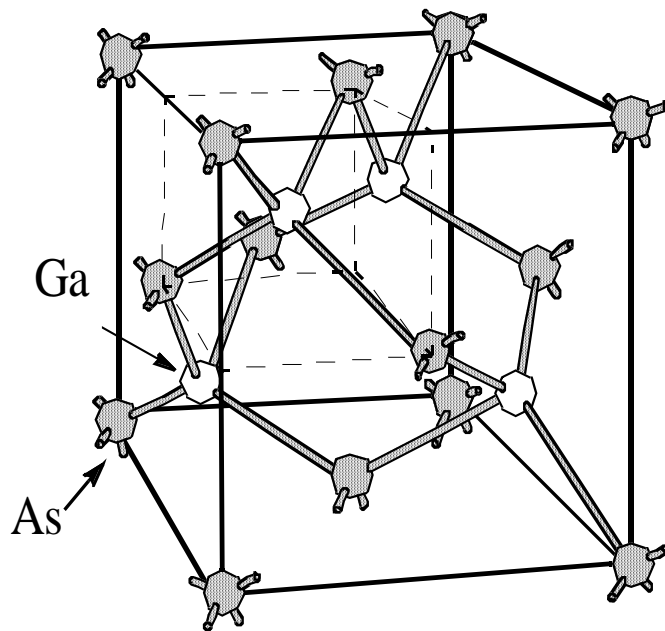
## *Dopants in Silicon*



- As, a Group V element, introduces conduction electrons and creates *N-type silicon*, and is called a *donor*.
- B, a Group III element, introduces holes and creates *P-type silicon*, and is called an *acceptor*.
- Donors and acceptors are known as dopants. Dopant ionization energy ~50meV (very low).

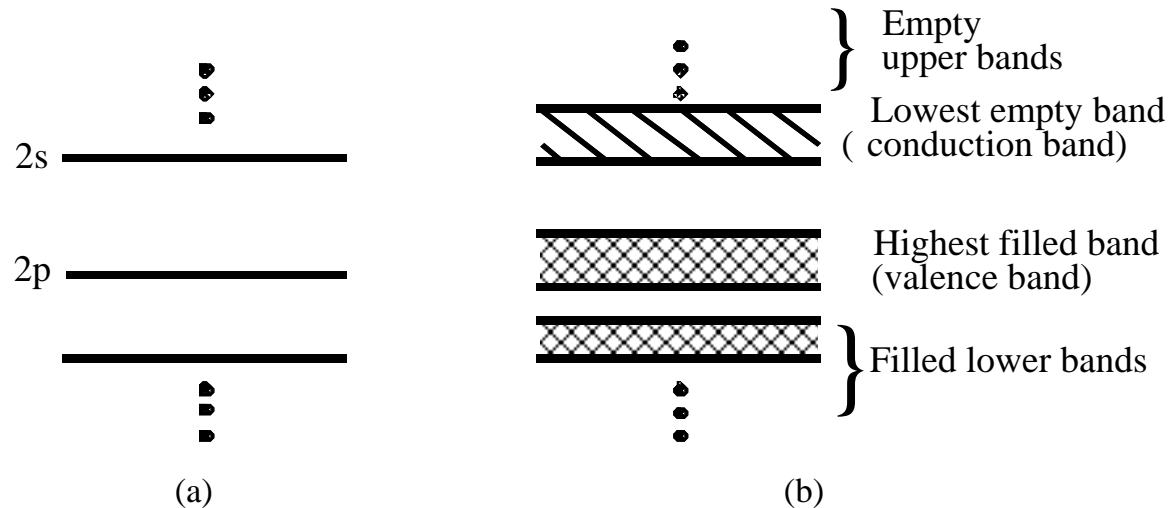
Hydrogen: 
$$E_{ion} = \frac{m_0 q^4}{8\epsilon_0^2 h^2} = 13.6 \text{ eV}$$

# *GaAs, III-V Compound Semiconductors, and Their Dopants*



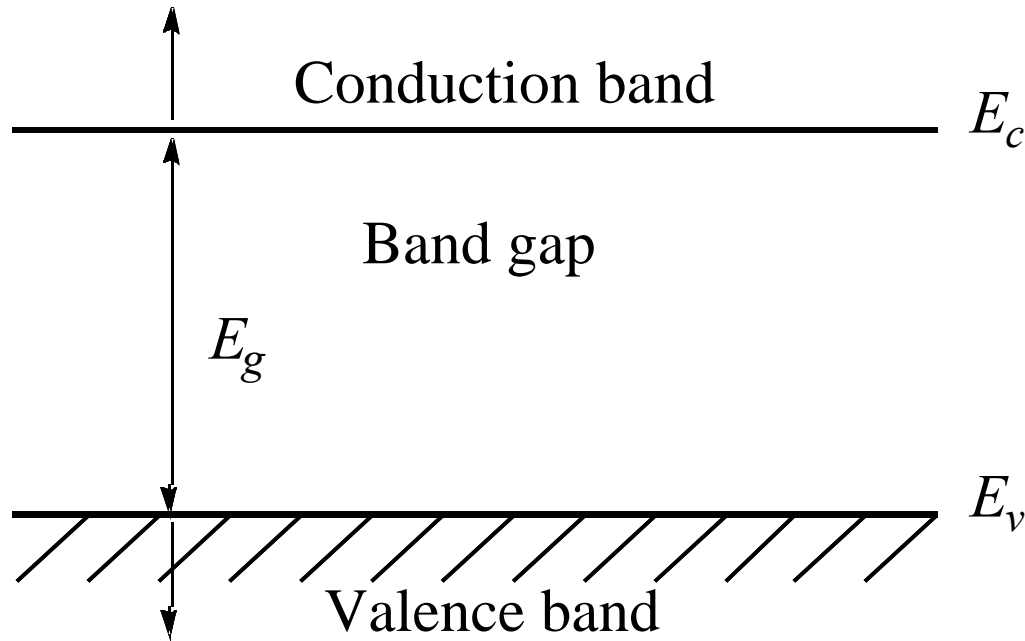
- GaAs has the same crystal structure as Si.
- GaAs, GaP, GaN are III-V compound semiconductors, important for optoelectronics.
- Which group of elements are candidates for donors? acceptors?

## 1.3 Energy Band Model



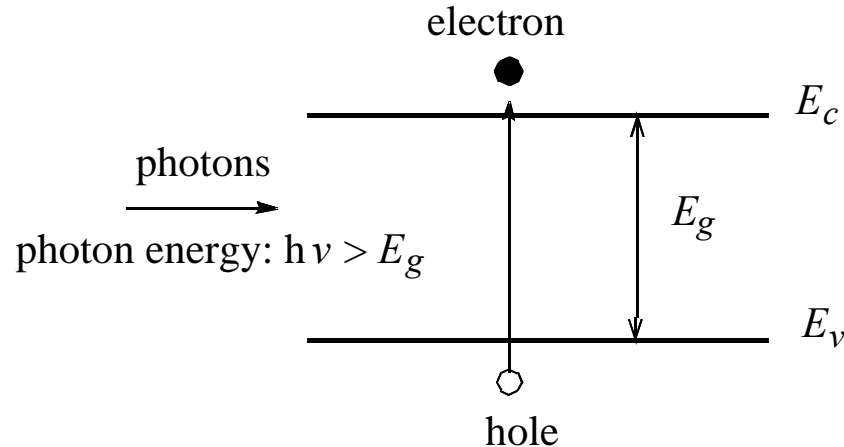
- Energy states of Si atom (a) expand into energy bands of Si crystal (b).
- The lower bands are filled and higher bands are empty in a semiconductor.
- The highest filled band is the ***valence band***.
- The lowest empty band is the ***conduction band***.

### 1.3.1 Energy Band Diagram



- **Energy band diagram** shows the bottom edge of conduction band,  $E_c$ , and top edge of valence band,  $E_v$ .
- $E_c$  and  $E_v$  are separated by the **band gap energy**,  $E_g$ .

## *Measuring the Band Gap Energy by Light Absorption*



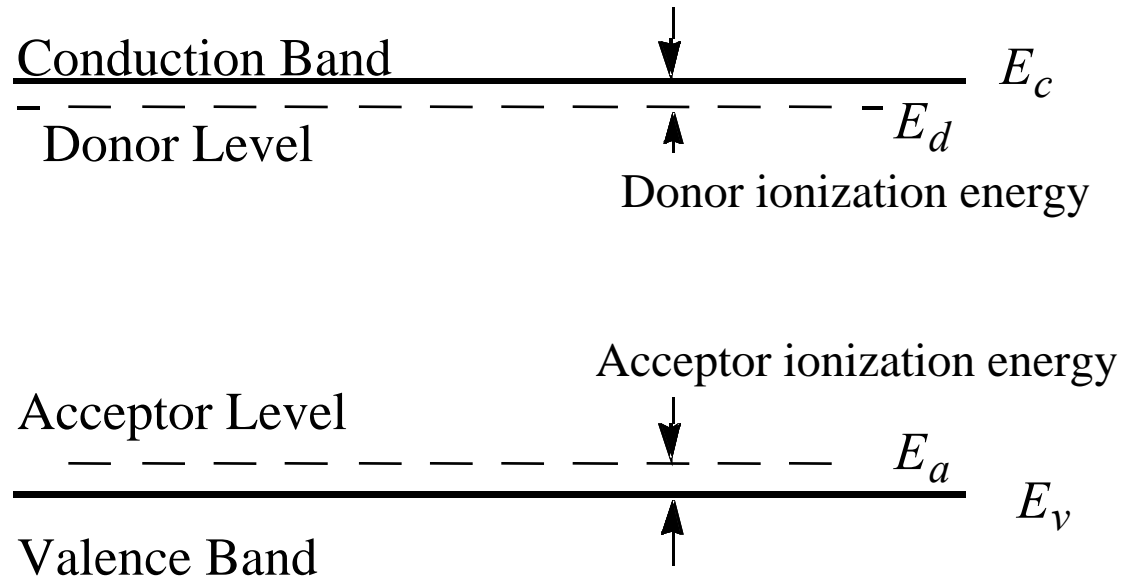
- $E_g$  can be determined from the minimum energy ( $h\nu$ ) of photons that are absorbed by the semiconductor.

**Bandgap energies of selected semiconductors**

Semiconductor	PbTe	Ge	Si	GaAs	GaP	Diamond
$E_g$ (eV)	0.31	0.67	1.12	1.42	2.25	6.0



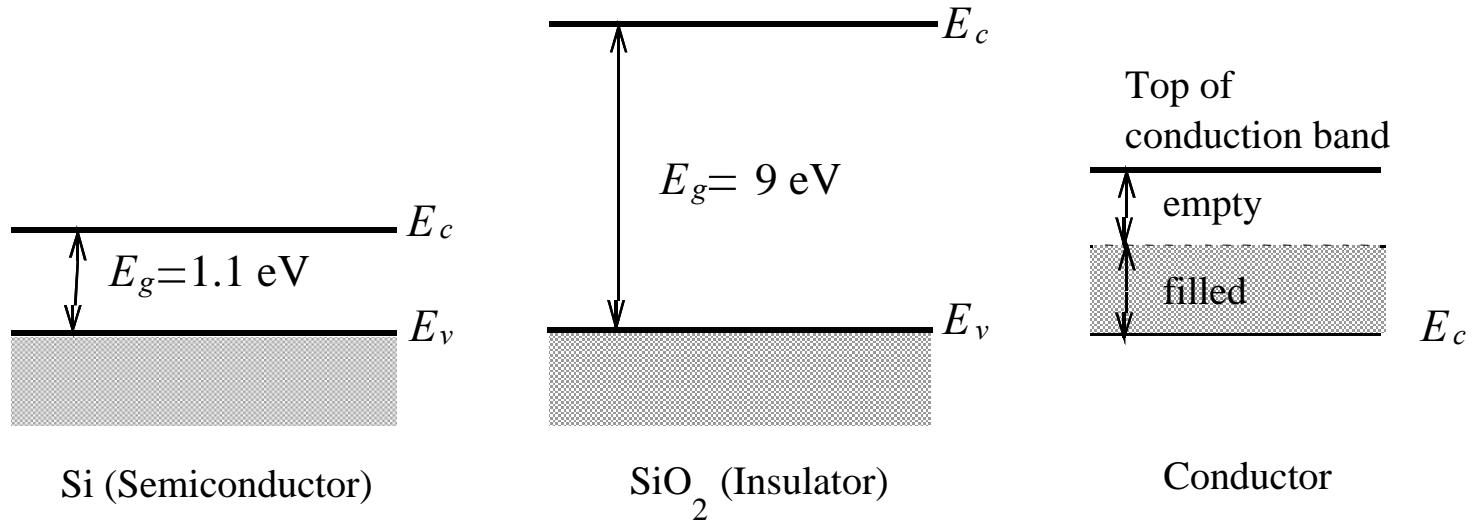
## 1.3.2 Donor and Acceptor Levels in the Band Model



### Ionization energy of selected donors and acceptors in silicon

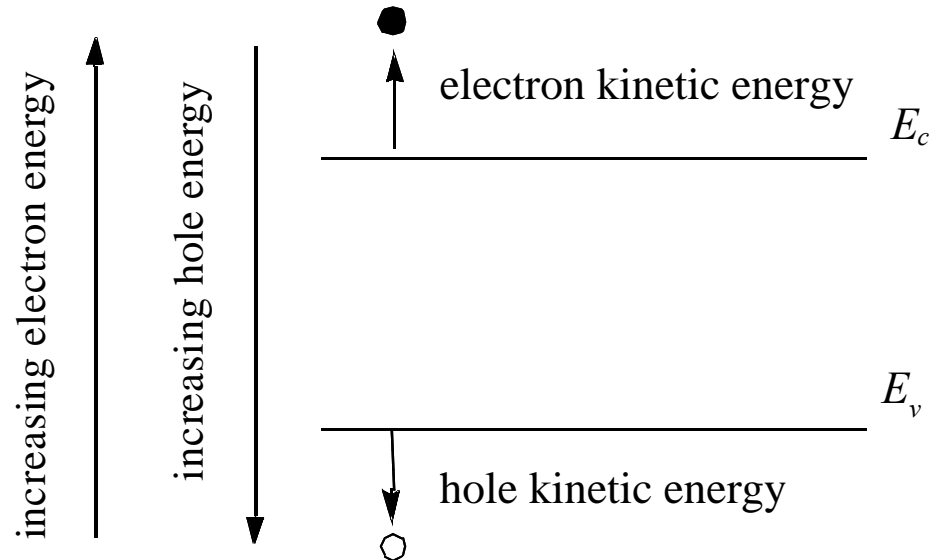
	Donors			Acceptors		
Dopant	Sb	P	As	B	Al	In
Ionization energy, $E_c - E_d$ or $E_a - E_v$ (meV)	39	44	54	45	57	160

## 1.4 Semiconductors, Insulators, and Conductors



- Totally filled bands and totally empty bands do not allow current flow. (Just as there is no motion of liquid in a totally filled or totally empty bottle.)
- Metal conduction band is half-filled.
- Semiconductors have lower  $E_g$ 's than insulators and can be doped.

## *1.5 Electrons and Holes*



- Both electrons and holes tend to seek their lowest energy positions.
- Electrons tend to fall in the energy band diagram.
- Holes float up like bubbles in water.

## 1.5.1 Effective Mass

In an electric field,  $\mathcal{E}$ , an electron or a hole accelerates.

$$a = \frac{-q\mathcal{E}}{m_n} \quad \text{electrons}$$

$$a = \frac{q\mathcal{E}}{m_p} \quad \text{holes}$$

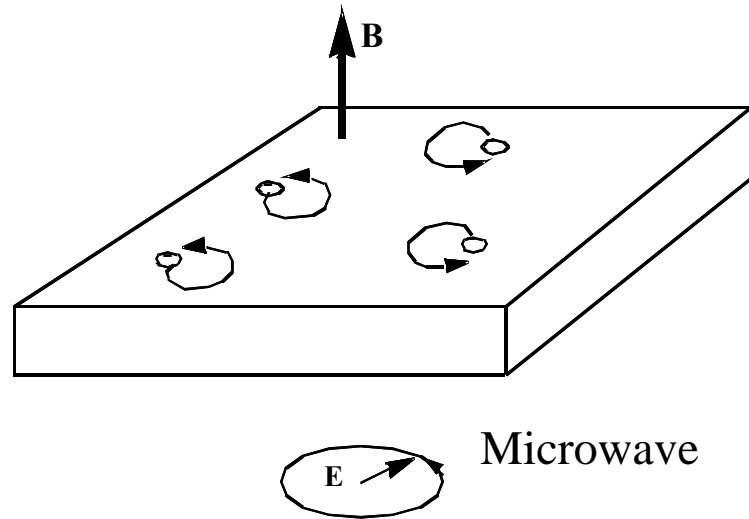
### Electron and hole effective masses

	Si	Ge	GaAs	GaP
$m_n/m_0$	0.26	0.12	0.068	0.82
$m_p/m_0$	0.39	0.30	0.50	0.60

## 1.5.2 How to Measure the Effective Mass

Cyclotron Resonance  
Technique

Centripetal force =  
Lorentzian force



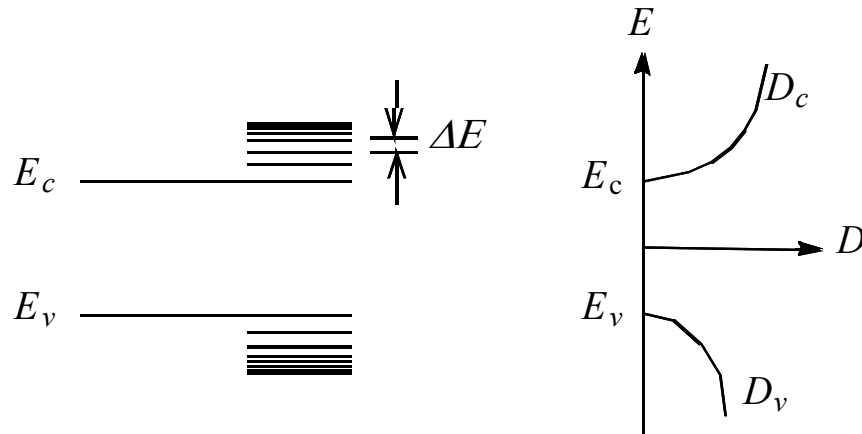
$$\frac{m_n v^2}{r} = qvB$$

$$v = \frac{qBr}{m_n}$$

$$f_{cr} = \frac{v}{2\pi r} = \frac{qB}{2\pi m_n}$$

$f_{cr}$  is the Cyclotron resonance frequency.  
It is independent of  $v$  and  $r$ . Electrons  
strongly absorb microwaves of that frequency.  
By measuring  $f_{cr}$ ,  $m_n$  can be found.

## 1.6 Density of States



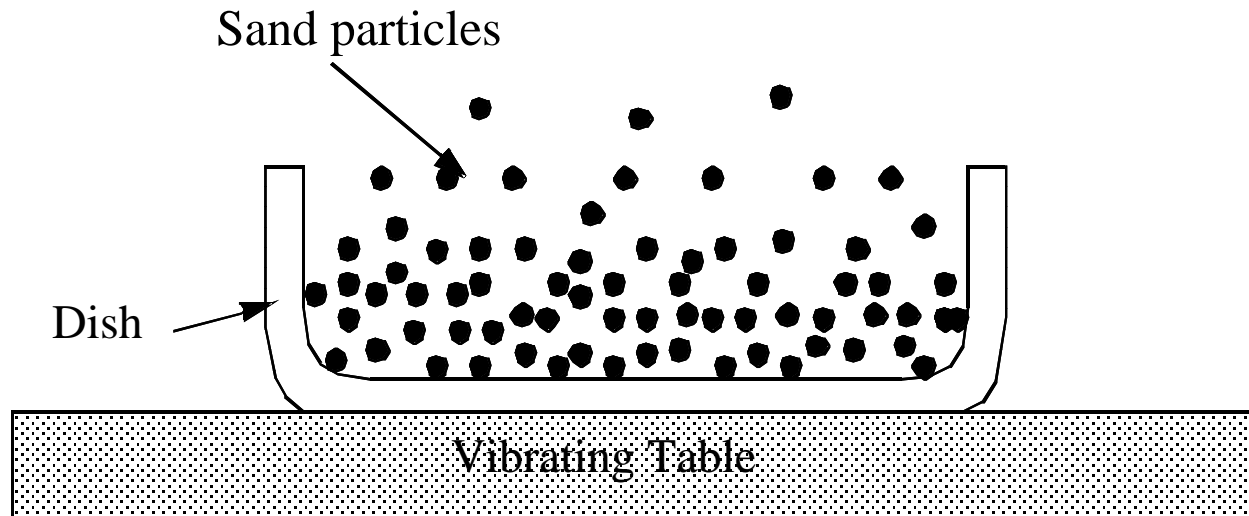
$$D_c(E) \equiv \frac{\text{number of states in } \Delta E}{\Delta E \cdot \text{volume}} \left( \frac{1}{\text{eV} \cdot \text{cm}^3} \right)$$

$$D_c(E) \equiv \frac{8\pi m_n \sqrt{2m_n(E - E_c)}}{h^3}$$

$$D_v(E) \equiv \frac{8\pi m_p \sqrt{2m_p(E_v - E)}}{h^3}$$

## ***1.7 Thermal Equilibrium***

### **1.7.1 An Analogy for Thermal Equilibrium**



- There is a certain probability for the electrons in the conduction band to occupy high-energy states under the agitation of thermal energy (vibrating atoms, etc.)

## 1.7.2 Fermi Function–The Probability of an Energy State Being Occupied by an Electron

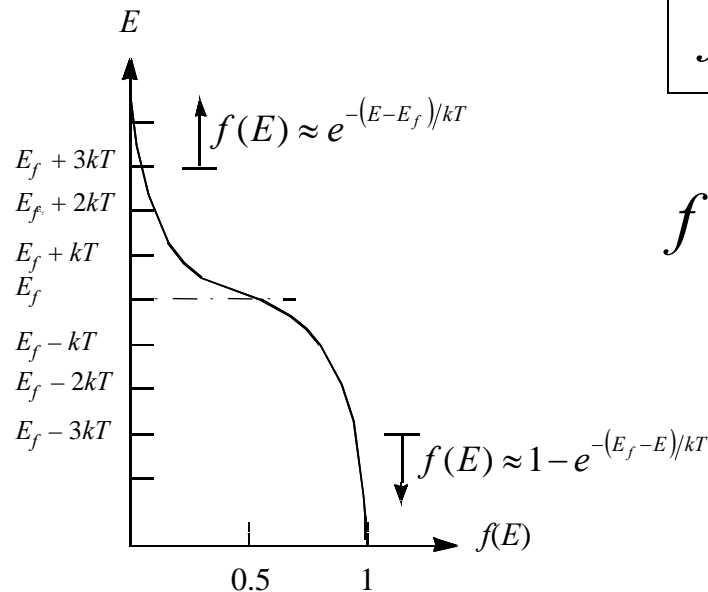
$$f(E) = \frac{1}{1 + e^{(E-E_f)/kT}}$$

$E_f$  is called the *Fermi energy* or the *Fermi level*.

Boltzmann approximation:

$$f(E) \approx e^{-(E-E_f)/kT} \quad E - E_f \gg kT$$

$$f(E) \approx 1 - e^{-(E_f-E)/kT} \quad E - E_f \ll -kT$$



***Remember: there is only one Fermi-level in a system at equilibrium.***



## ***1.8 Electron and Hole Concentrations***

### **1.8.1 Derivation of $n$ and $p$ from $D(E)$ and $f(E)$**

$$n = \int_{E_c}^{\text{top of conduction band}} f(E) D_c(E) dE$$

$$n = \frac{8\pi m_n \sqrt{2m_n}}{h^3} \int_{E_c}^{\infty} \sqrt{E - E_c} e^{-(E - E_f)/kT} dE$$

$$= \frac{8\pi m_n \sqrt{2m_n}}{h^3} e^{-(E_c - E_f)/kT} \int_0^{\infty} \sqrt{E - E_c} e^{-(E - E_c)/kT} dE$$

## *Electron and Hole Concentrations*

$$n = N_c e^{-(E_c - E_f)/kT}$$

$$N_c \equiv 2 \left[ \frac{2\pi m_n kT}{h^2} \right]^{3/2}$$

$$p = N_v e^{-(E_f - E_v)/kT}$$

$$N_v \equiv 2 \left[ \frac{2\pi m_p kT}{h^2} \right]^{3/2}$$

$N_c$  is called the *effective density of states (of the conduction band)* .

$N_v$  is called the *effective density of states of the valence band*.

**Remember:** the closer  $E_f$  moves up to  $N_c$ , the larger  $n$  is; the closer  $E_f$  moves down to  $N_v$ , the larger  $p$  is.

**For Si,**  $N_c = 2.8 \times 10^{19} \text{ cm}^{-3}$  and  $N_v = 1.04 \times 10^{19} \text{ cm}^{-3}$ .

## 1.8.2 The Fermi Level and Carrier Concentrations

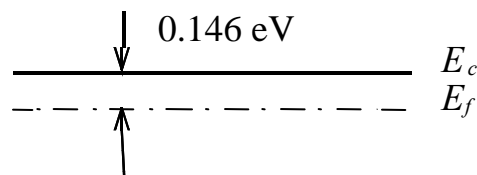
Where is  $E_f$  for  $n = 10^{17} \text{ cm}^{-3}$ ? And for  $p = 10^{14} \text{ cm}^{-3}$ ?

**Solution:** (a)  $n = N_c e^{-(E_c - E_f)/kT}$

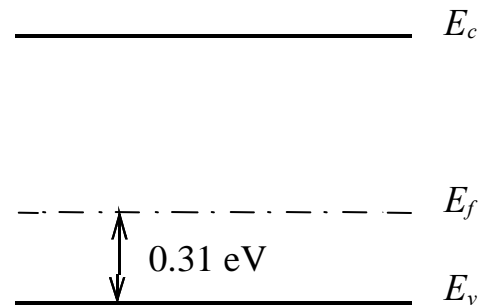
$$E_c - E_f = kT \ln(N_c/n) = 0.026 \ln(2.8 \times 10^{19} / 10^{17}) = 0.146 \text{ eV}$$

(b) For  $p = 10^{14} \text{ cm}^{-3}$ , from Eq.(1.8.8),

$$E_f - E_v = kT \ln(N_v/p) = 0.026 \ln(1.04 \times 10^{19} / 10^{14}) = 0.31 \text{ eV}$$

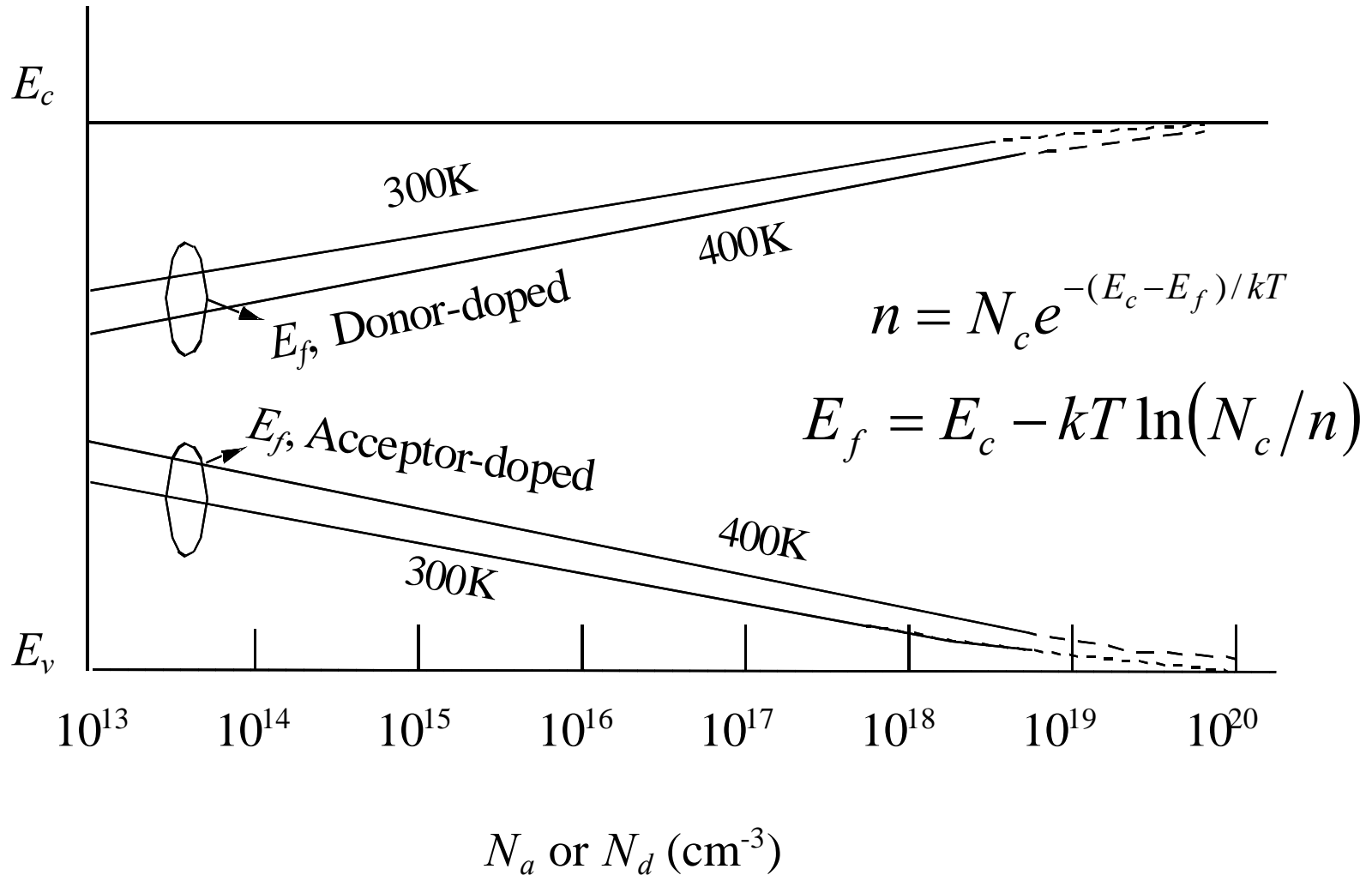


(a)



(b)

## 1.8.2 The Fermi Level and Carrier Concentrations



### 1.8.3 The $np$ Product and the Intrinsic Carrier Concentration

Multiply  $n = N_c e^{-(E_c - E_f)/kT}$  and  $p = N_v e^{-(E_f - E_v)/kT}$

$$np = N_c N_v e^{-(E_c - E_v)/kT} = N_c N_v e^{-E_g/kT}$$

$$np = n_i^2$$

$$n_i = \sqrt{N_c N_v} e^{-E_g/2kT}$$

- In an intrinsic (undoped) semiconductor,  $n = p = n_i$ .
- $n_i$  is the ***intrinsic carrier concentration***,  $\sim 10^{10} \text{ cm}^{-3}$  for Si.

## ***EXAMPLE: Carrier Concentrations***

**Question:** *What is the hole concentration in an N-type semiconductor with  $10^{15} \text{ cm}^{-3}$  of donors?*

**Solution:**  $n = 10^{15} \text{ cm}^{-3}$ .

$$p = \frac{n_i^2}{n} \approx \frac{10^{20} \text{ cm}^{-3}}{10^{15} \text{ cm}^{-3}} = 10^5 \text{ cm}^{-3}$$

*After increasing  $T$  by  $60^\circ\text{C}$ ,  $n$  remains the same at  $10^{15} \text{ cm}^{-3}$  while  $p$  increases by about a factor of 2300 because  $n_i^2 \propto e^{-E_g/kT}$ .*

**Question:** *What is  $n$  if  $p = 10^{17} \text{ cm}^{-3}$  in a P-type silicon wafer?*

**Solution:**

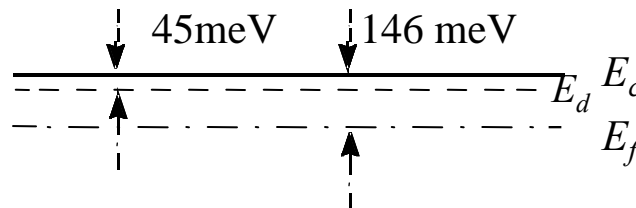
$$n = \frac{n_i^2}{p} \approx \frac{10^{20} \text{ cm}^{-3}}{10^{17} \text{ cm}^{-3}} = 10^3 \text{ cm}^{-3}$$

### ***EXAMPLE: Complete ionization of the dopant atoms***

$N_d = 10^{17} \text{ cm}^{-3}$ . What fraction of the donors are not ionized?

***Solution:*** First assume that all the donors ***are*** ionized.

$$n = N_d = 10^{17} \text{ cm}^{-3} \Rightarrow E_f = E_c - 146 \text{ meV}$$



\_\_\_\_\_  $E_v$

$$\text{Probability of non-ionization} \approx \frac{1}{1 + e^{(E_d - E_f)/kT}} = \frac{1}{1 + e^{((146 - 45) \text{ meV})/26 \text{ meV}}} = 0.02$$

*Therefore, it is reasonable to assume complete ionization, i.e.,  $n = N_d$ .*

## ***1.9 General Effects of Doping on $n$ and $p$***

Charge neutrality:  $n + N_a = p + N_d$

$$np = n_i^2$$

$$p = \frac{N_a - N_d}{2} + \left[ \left( \frac{N_a - N_d}{2} \right)^2 + n_i^2 \right]^{1/2}$$

$$n = \frac{N_d - N_a}{2} + \left[ \left( \frac{N_d - N_a}{2} \right)^2 + n_i^2 \right]^{1/2}$$



## ***1.9 General Effects of Doping on $n$ and $p$***

**I.**  $N_d - N_a \gg n_i$  (i.e., N-type)

$$n = N_d - N_a$$

$$p = n_i^2 / n$$

If  $N_d \gg N_a$  ,  $n = N_d$  and  $p = n_i^2 / N_d$

**II.**  $N_a - N_d \gg n_i$  (i.e., P-type)

$$p = N_a - N_d$$

$$n = n_i^2 / p$$

If  $N_a \gg N_d$  ,  $p = N_a$  and  $n = n_i^2 / N_a$

## ***EXAMPLE: Dopant Compensation***

What are  $n$  and  $p$  in Si with (a)  $N_d = 6 \times 10^{16} \text{ cm}^{-3}$  and  $N_a = 2 \times 10^{16} \text{ cm}^{-3}$  and (b) additional  $6 \times 10^{16} \text{ cm}^{-3}$  of  $N_a$ ?

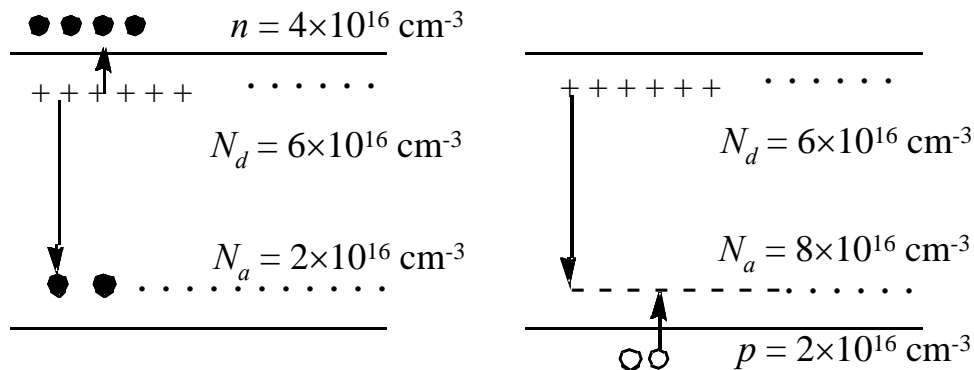
(a)  $n = N_d - N_a = 4 \times 10^{16} \text{ cm}^{-3}$

$$p = n_i^2 / n = 10^{20} / 4 \times 10^{16} = 2.5 \times 10^3 \text{ cm}^{-3}$$

(b)  $N_a = 2 \times 10^{16} + 6 \times 10^{16} = 8 \times 10^{16} \text{ cm}^{-3} > N_d!$

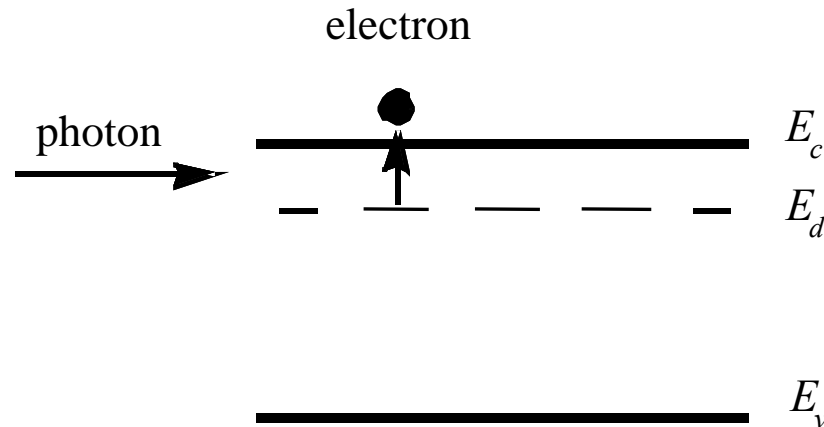
$$p = N_a - N_d = 8 \times 10^{16} - 6 \times 10^{16} = 2 \times 10^{16} \text{ cm}^{-3}$$

$$n = n_i^2 / p = 10^{20} / 2 \times 10^{16} = 5 \times 10^3 \text{ cm}^{-3}$$

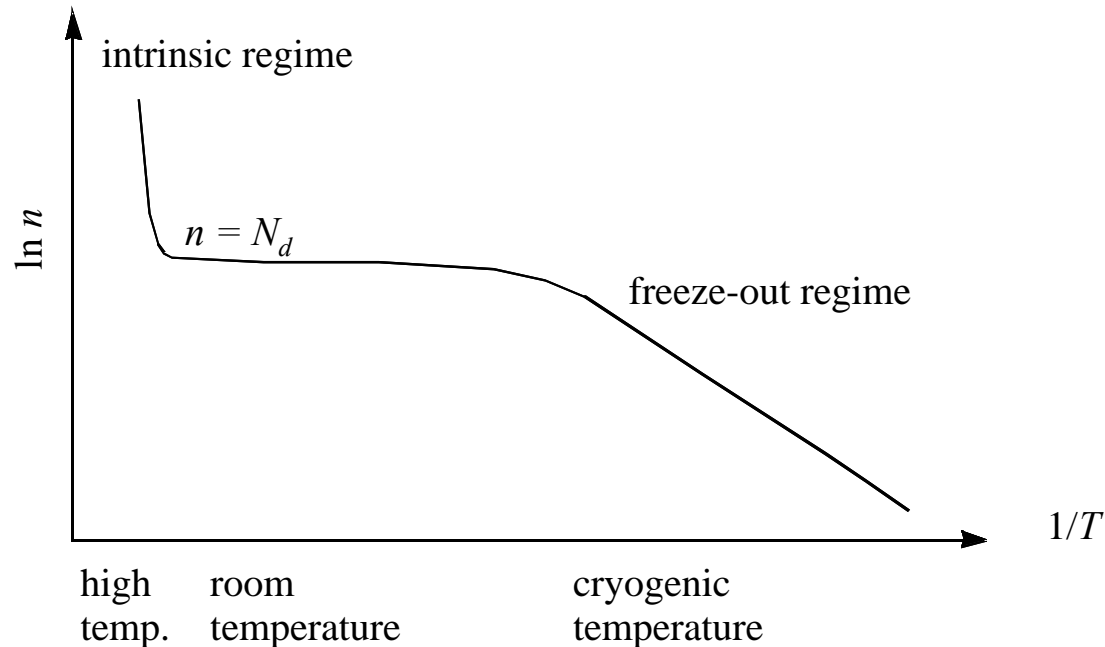


## *Infrared Detector Based on Freeze-out*

To image the black-body radiation emitted by tumors requires a photodetector that responds to  $h\nu$ 's around 0.1 eV. In doped Si operating in the freeze-out mode, conduction electrons are created when the infrared photons provide the energy to ionized the donor atoms.



## 1.10 Carrier Concentrations at Extremely High and Low Temperatures



high T:  $n = p = n_i = \sqrt{N_c N_v} e^{-E_g/2kT}$

low T:  $n = \left[ \frac{N_c N_d}{2} \right]^{1/2} e^{-(E_c - E_d)/2kT}$

## ***1.11 Chapter Summary***

Energy band diagram. Acceptor. Donor.  $m_n$ ,  $m_p$ . Fermi function.  $E_f$ .

$$n = N_c e^{-(E_c - E_f)/kT}$$

$$p = N_v e^{-(E_f - E_v)/kT}$$

$$n = N_d - N_a$$

$$p = N_a - N_d$$

$$np = n_i^2$$